Supplementary Information (SI) for Journal of Materials Chemistry A. This journal is © The Royal Society of Chemistry 2025

## **Supporting Information for:**

## Thermally Enhanced Substrate Design for Flexible Thermoelectric Devices via Ultrasonic Welding

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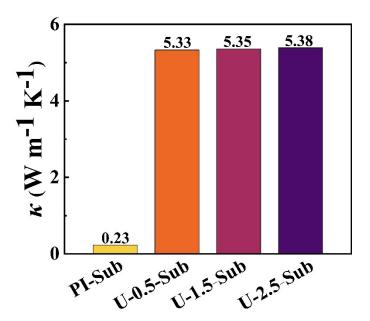
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## This PDF includes:

- A. Figures S1 to S5
- B. Videos S1 to S2



**Figure S1.** Thermal conductivity of the thermal conductive silicone pad-PI laminated substrate with the silicone pad of different thickness. PI-Sub: the PI substrate, U-0.5-Sub: laminated substrate with the silicone pad thickness of 0.5 mm, U-1.5-Sub: laminated substrate with the silicone pad thickness of 1.5 mm, U-2.5-Sub: laminated substrate with the silicone pad thickness of 2.5 mm.

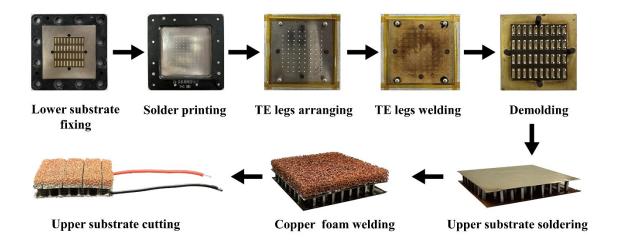


Figure S2. Fabrication process of the f-TED.

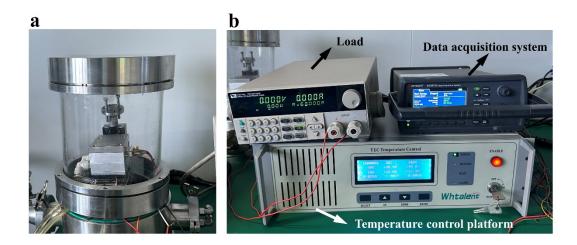


Figure S3. (a) Temperature control platform; (b) Output performance test equipment.

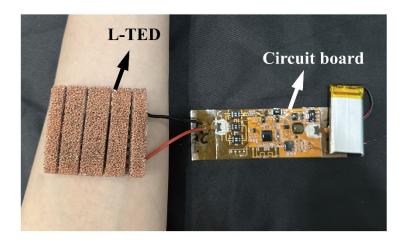
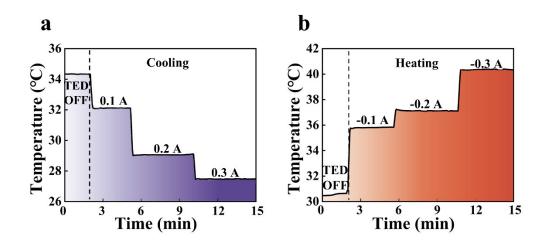


Figure S4. Circuit diagram of the wearable system.



**Figure S5.** (a) Cooling performance of P-TED; (b) Heating performance of P-TED. P-TED: the f-TED with the PI substrate.

## **B:** Videos

**Video S1.** Heating performance of the wearable system comprising L-TED, a control circuit board, and a mobile terminal.

**Video S2.** Cooling performance of the wearable system comprising L-TED, a control circuit board, and a mobile terminal.